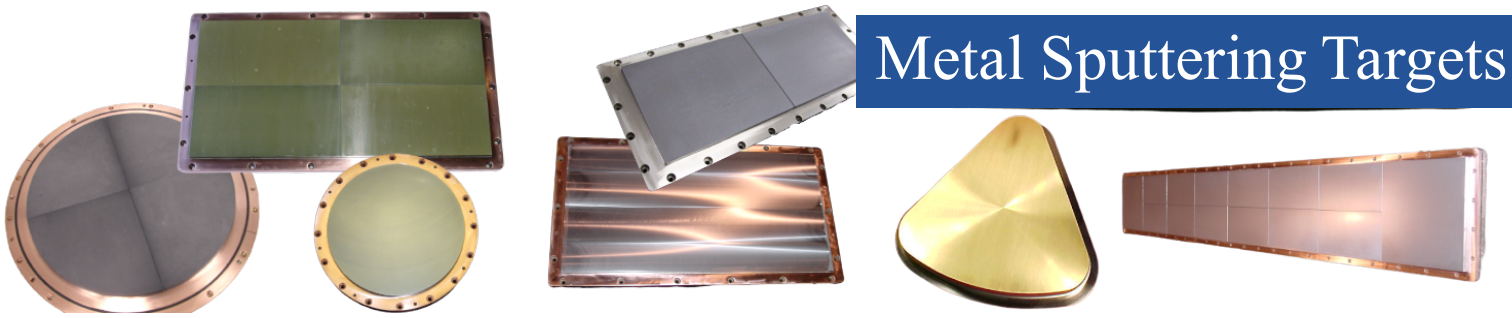




# SCI Engineered Materials



## Metal Sputtering Targets

Material	Purity	Forms
Al	99%-99.999%	Planar & Rotatable
Al (reflective)	95%	Planar
Cr	99.5% - 99.95%	Planar & Rotatable
Cu	99.99%	Planar & Rotatable
Mo	99.95%	Planar & Rotatable
Nb	99.95%	Planar & Rotatable
Ni	99.99%	Planar
Ni/Cr (80/20 wt%)	99.95%	Planar & Rotatable
Ni/V (93/7 wt%)	99.9% - 99.95%	Planar & Rotatable
Ru	99.9%	Planar
Ta	99.95%	Planar
Ti	99.2% - 99.995%	Planar & Rotatable
Zr	99.2%	Planar & Rotatable
V	99.9%	Planar
W	99.90%	Planar

